

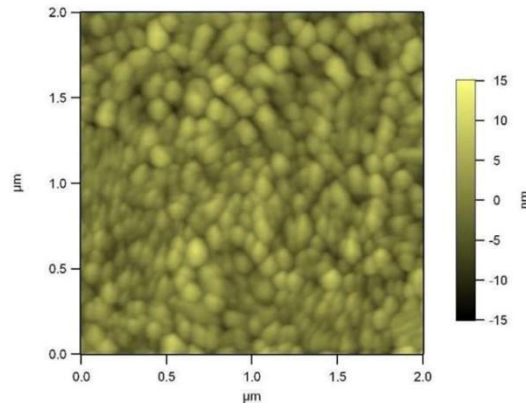
**Supplementary Material for**  
**Optoelectronic neuro-synaptic behaviors of antiferroelectric NaNbO<sub>3</sub>/n-GaN**  
**heterostructures**

Huijuan Dong(董慧娟)<sup>1,2</sup>, Kexin Jin(金克新)<sup>2</sup>, Bingcheng Luo(罗炳成)<sup>2\*</sup>

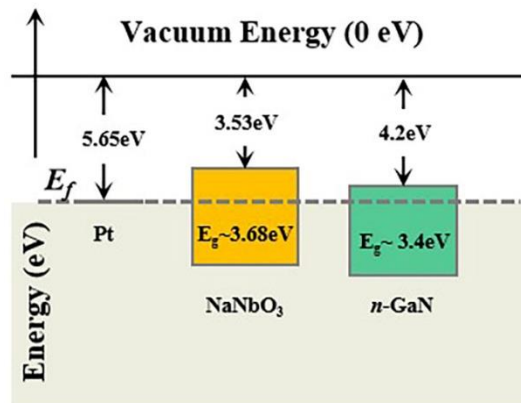
<sup>1</sup>Department of Physics, Changzhi University, Changzhi 046011, China

<sup>2</sup>School of Physical Science and Technology, Northwestern Polytechnical University,  
Xi'an 710072, China

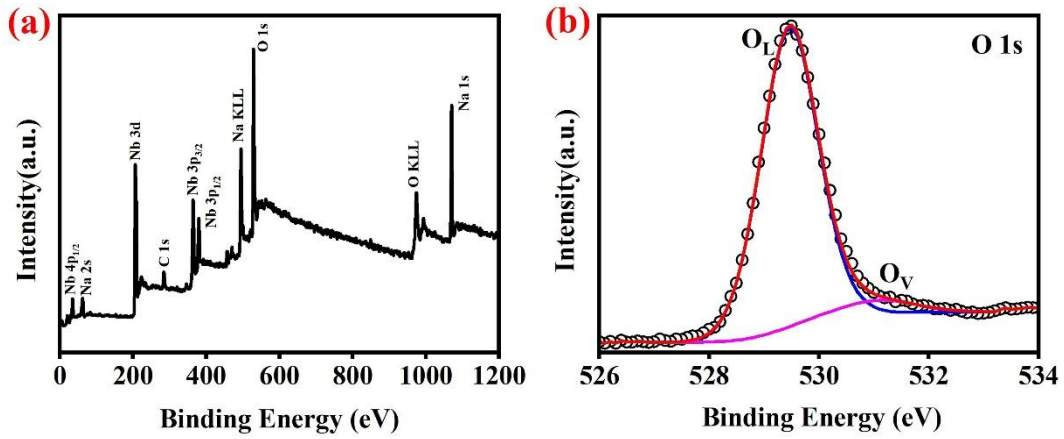
\* Electronic mail: [luobingcheng@nwpu.edu.cn](mailto:luobingcheng@nwpu.edu.cn)



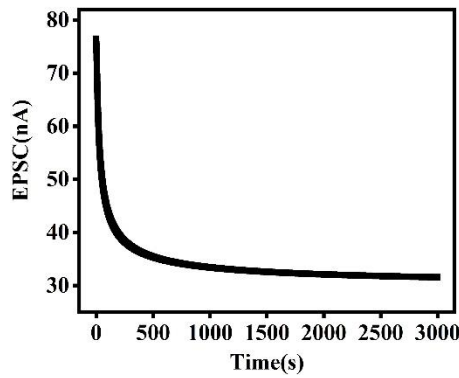
**Fig. S1 AFM image of NNO/n-GaN heterostructure.** The roughness of NNO thin film is  $2.8 \pm 0.1$  nm.



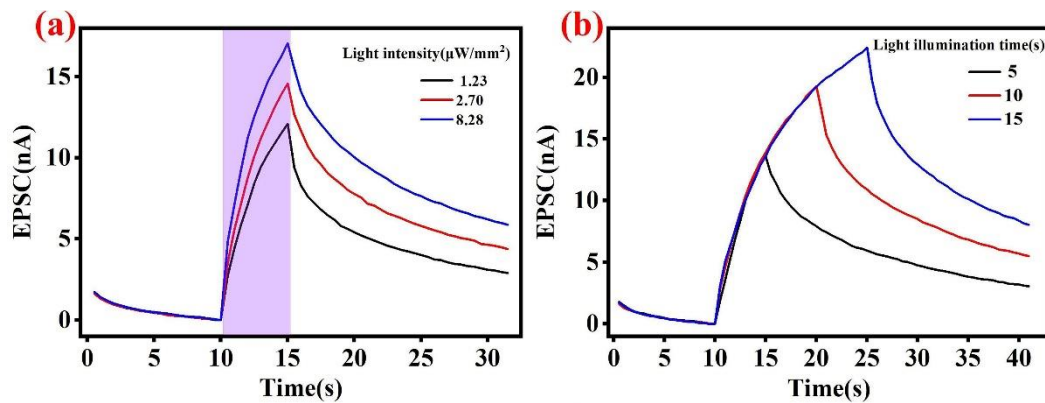
**Fig. S2 Energy level diagrams of various materials for NNO/n-GaN heterostructure.**



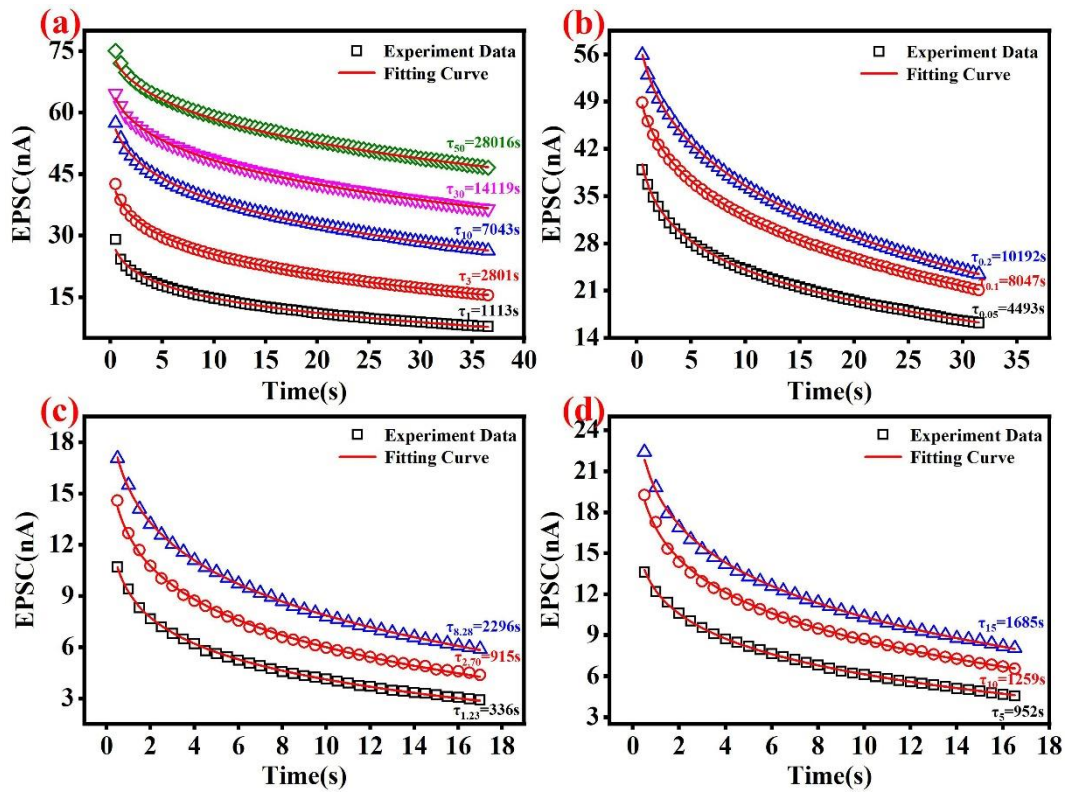
**Fig. S3 XPS spectra of NNO/n-GaN heterostructure. (a) XPS survey spectra, (b) XPS narrow scan spectrum of O 1s.** The XPS survey spectrum reveals that the samples mainly contain Na, Nb, and O element. The high-resolution O 1s XPS peak can be de-convoluted into two distinct peaks, respectively corresponding to the lattice oxygen (O<sub>L</sub>) and oxygen vacancies (O<sub>V</sub>), demonstrating the presence of oxygen vacancies.



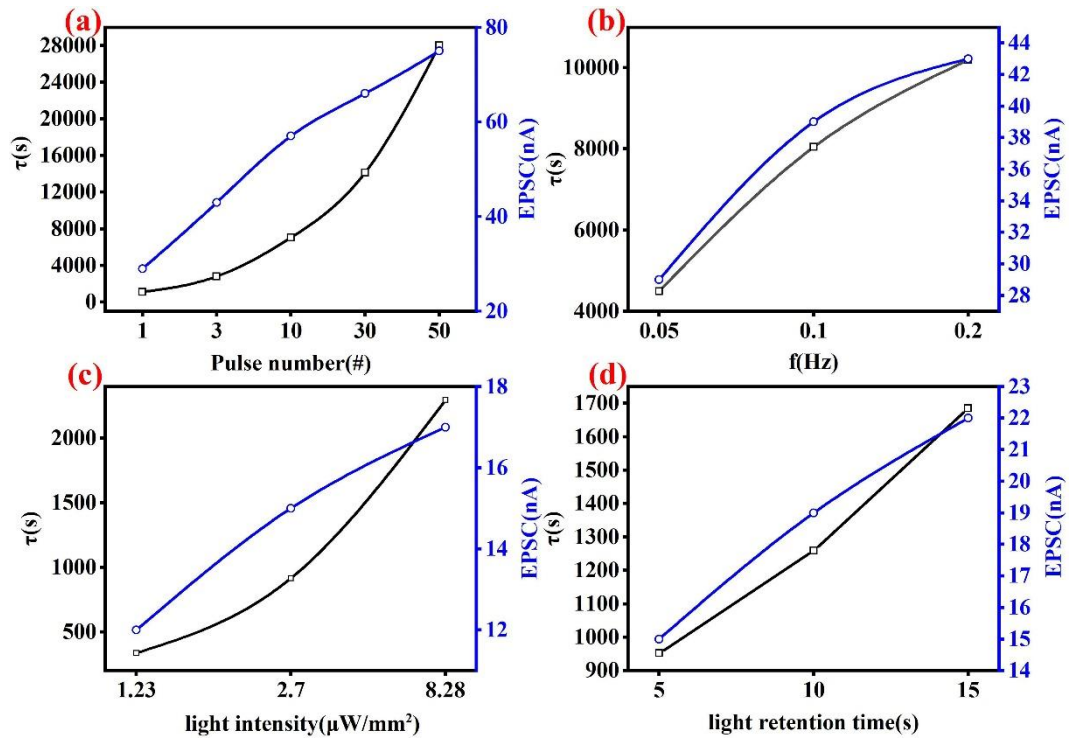
**Fig. S4 Retention characteristics of NNO/n-GaN heterostructure after stimulation with 50 light pulses of intensity 2.7  $\mu\text{W}/\text{mm}^2$ .**



**Fig. S5** Current-time (I-t) characteristics under optical pulses with (a) different intensities and (b) different illuminating times of NNO/n-GaN heterostructure. Notably, variable light intensities and light retention times can also be used to perform STM, LTM, and STM-LTM conversion. Higher light intensity or longer retention time will induce higher photocurrent response, and the photocurrent will also be maintained at a higher level after stimulation of light pulse, resulting in the STM-LTM conversion [1].



**Fig. S6** Current decay and fitting results under different optical pulse numbers (a), frequencies (b), light intensities (c) and illuminating times (d) of NNO/n-GaN heterostructure. With the increase of pulse number, light frequency, light intensity and light retention time, the value of characteristic time  $\tau$  increases, which is strong evidence for the transition from STM to LTM [2].



**Fig. S7  $\tau$  and EPSC as a function of pulse number (a), frequencies (b), light intensities (c) and illuminating times (d) of NNO/n-GaN heterostructure.**

## References

- [1] D. C. Hu, R Yang, L Jiang, et al., "Memristive Synapses with Photoelectric Plasticity Realized in  $\text{ZnO}_{1-x}/\text{AlO}_y$  Heterojunction," *ACS Appl. Mater. Inter.* **10**, 6463(2018).
- [2] K Wang, S Dai, Y Zhao, et al., "Light-Stimulated Synaptic Transistors Fabricated by a Facile Solution Process Based on Inorganic Perovskite Quantum Dots and Organic Semiconductors," *Small* **15**, 1900010 (2019).